

[54] COMBINED HIGH INTENSITY LIGHT AND HOLDER FOR SILICON WAFERS OR SIMILAR ARTICLES

2,559,627 7/1951 Johnson ..... 362/197 X  
2,725,788 12/1955 Pflieger ..... D26/49 X

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[\*\*] Term: 14 Years

[21] Appl. No.: 613,429

[22] Filed: May 24, 1984

[52] U.S. Cl. .... D26/38; D26/43

[58] Field of Search ..... D26/24, 37-51; 362/157, 158, 183-208, 804

[56] References Cited

U.S. PATENT DOCUMENTS

- D. 182,053 2/1958 Weston et al. .... D26/38
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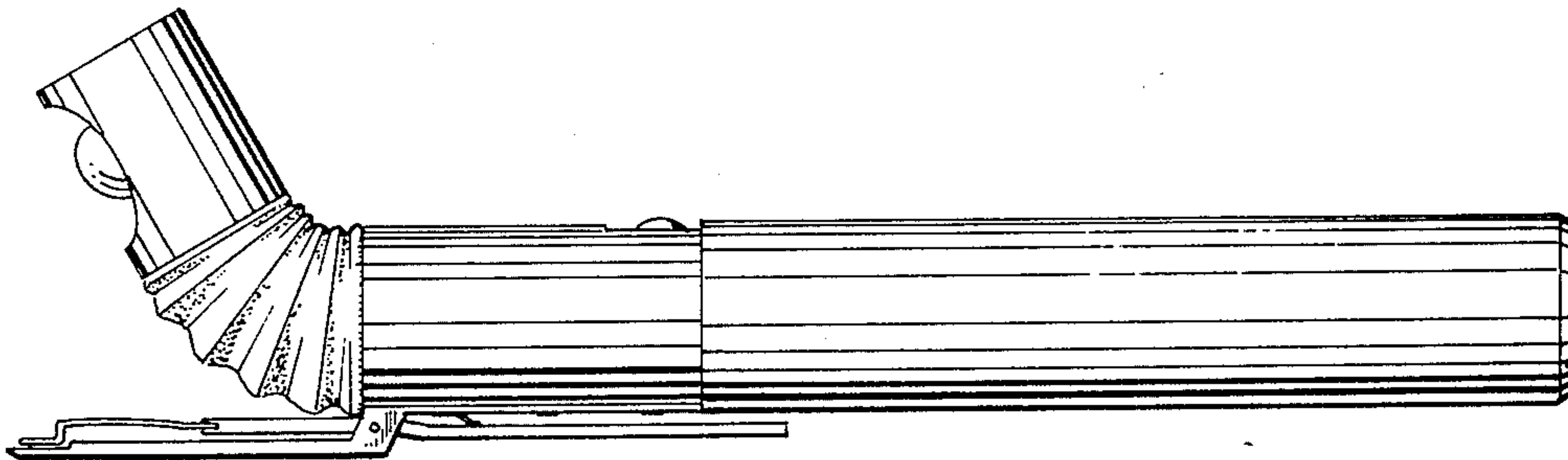
Primary Examiner—Susan J. Lucas  
Attorney, Agent, or Firm—Palmatier & Sjoquist

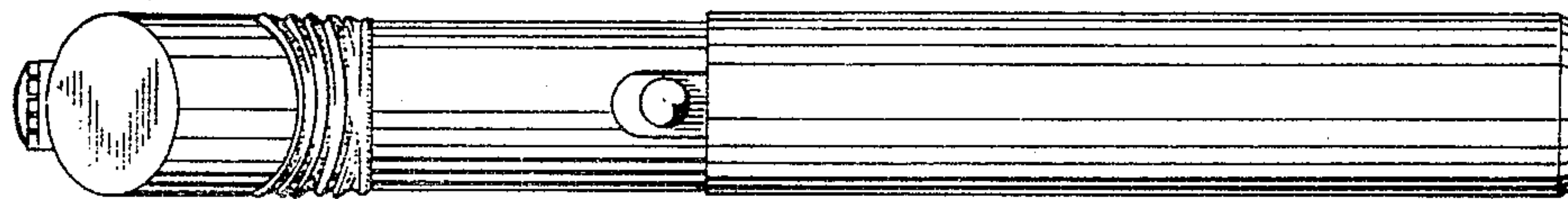
[57] CLAIM

The ornamental design for a combined high intensity light and holder for silicon wafers or similar articles, as shown.

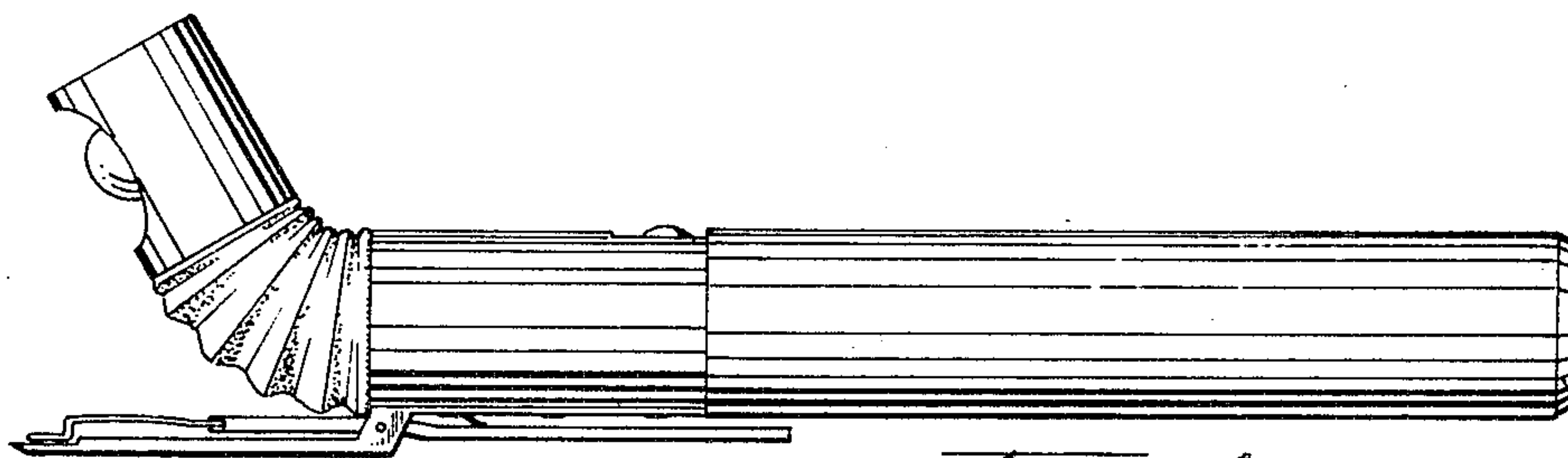
DESCRIPTION

FIG. 1 is a front side elevation view of the combined high intensity light and holder for silicon wafers or similar articles;  
FIG. 2 is a top plan view thereof;  
FIG. 3 is a bottom plan view thereof;  
FIG. 4 is a rear side elevation view thereof;  
FIG. 5 is an elevation view of the right end thereof; and  
FIG. 6 is an elevation view of the left end thereof.

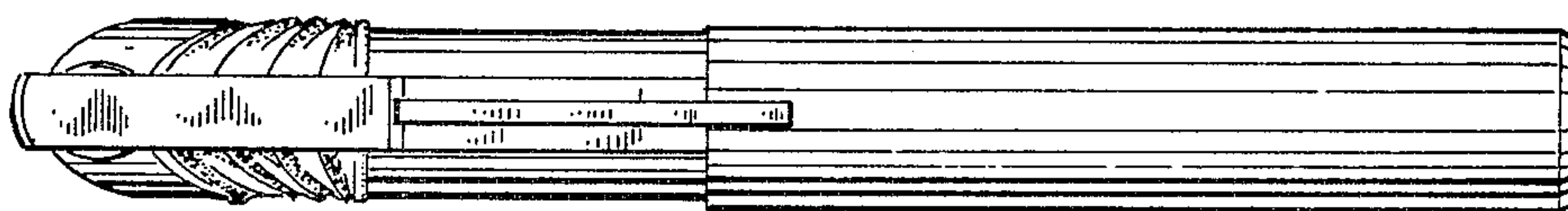




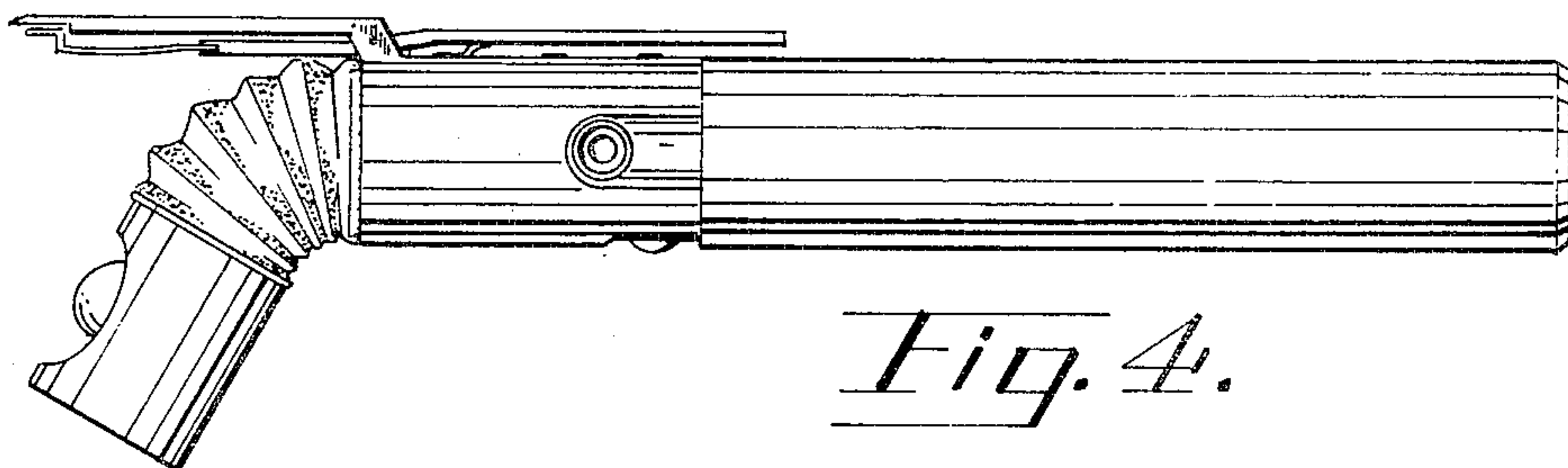
*Fig. 2.*



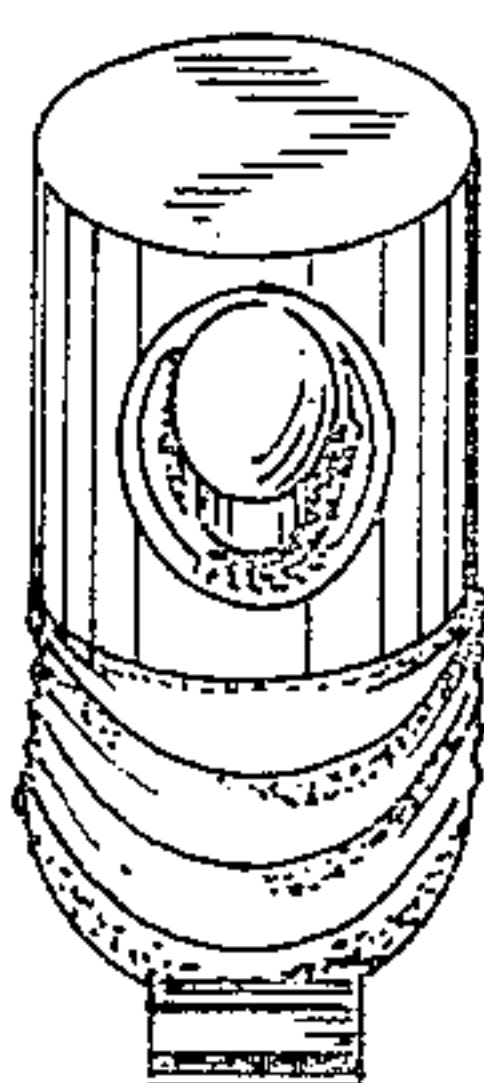
*Fig. 1.*



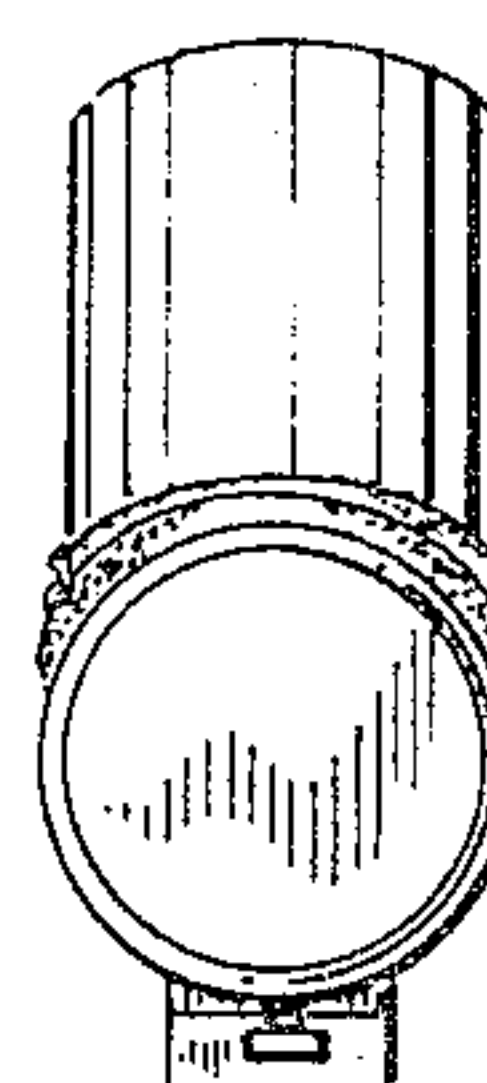
*Fig. 3.*



*Fig. 4.*



*Fig. 5.*



*Fig. 6.*